Laser Ablative Structural Modification of Poly(ethylene-alt-maleic anhydride)

Josef Pola* and Jaroslav Kupčik

Laser Chemistry Group, Institute of Chemical Process Fundamentals, Academy of Sciences of the Czech Republic, 16502 Prague, Czech Republic

Sardar M. A. Durani, Ehsan E. Khavaja, and Husain M. Masoudi*

Center for Applied Physical Sciences, Research Institute, King Fahd University of Petroleum and Minerals, 31261 Dhahran, Saudi Arabia

Zdeněk Bastl

J. Heyrovský Institute of Physical Chemistry, Academy of Sciences of the Czech Republic, 18223 Prague, Czech Republic

Jan Šubrt

Institute of Inorganic Chemistry, Academy of Sciences of the Czech Republic, 250 68 Řež, Czech Republic

Received April 14, 2003. Revised Manuscript Received July 30, 2003

Pulsed IR laser ablation of poly(ethylene-alt-maleic anhydride) results in the deposition of polymeric films possessing the same ratio of anhydride and $-CH_2-$ groups and represents a very rare example of laser ablative deposition of polymeric films that are structurally identical to the ablated polymer. This process differs from the conventional thermolysis of poly(ethylene-alt-maleic anhydride) that is controlled by expulsion of CO_2 and CO and yields a nonpolar polymeric residue. The IR laser ablation of poly(ethylene-alt-maleic anhydride) in sodium metasilicate affords deposition of polymeric films containing carboxylate ($-CO_2$) groups. This process is the first example of reactive ablation in which the deposited polymeric film incorporates constituents of two different species exposed to laser radiation.